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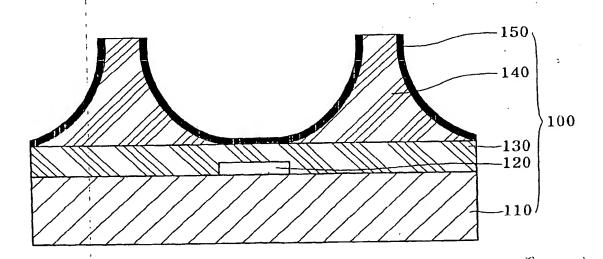
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(54) Title: REAR PLATE FOR PLASMA DISPLAY PANEL



(57) Abstract: Disclosed is a rear plate of a plasma display panel. In the rear plate, a dielectric layer or a barrier wall layer is formed by forming slurry in a tape of a green tape and then attaching the green tape to upper surfaces of electrodes and a glass substrate. Therefore, a PDP employing a rear plate according to the present invention has superior electric and optical characteristics.

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#### REAR PLATE FOR PLASMA DISPLAY PANEL

#### Technical Field

The present invention relates to a rear plate of a plasma display panel.

## Background Art

As generally known in the art, a plasma display panel (PDP) is a display device having a front glass substrate and a rear glass substrate between which a discharge space is formed, so that plasma discharge may generate in the discharge space, thereby causing phosphors in the discharge space to be excited and emit light, so as to display a screen. In comparison with liquid crystal panel, the PDP can display an image at a higher speed and can easily realize a larger screen. Therefore, PDPs are employed in a field of a television with a higher quality and a larger screen.

Hereinafter, an AC PDP, which is currently the mainstream of PDPs, will be described.

A PDP includes a front plate and a rear plate assembled in parallel with each other. The front plate includes a front glass substrate, a plurality of discharge sustaining electrodes formed on a lower surface of the front glass substrate, bus electrodes formed on lower surfaces of the discharge sustaining electrodes, a dielectric layer covering the discharge sustaining electrodes and the bus electrodes, and a protection layer formed on a lower surface of the

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dielectric layer. Further, the rear plate includes a rear glass substrate, address electrodes formed on an upper surface of the rear glass substrate, a dielectric layer formed on upper surfaces of the address electrodes, barrier walls formed on an upper surface of the dielectric layer to form discharge cells, and phosphorous layers formed on surfaces of the barrier walls. Herein, two discharge sustaining electrodes are disposed in each discharge cell.

Therefore, the address electrodes and discharge sustaining electrodes cause discharge in the discharge cells, and ultraviolet rays generated by the discharge excites the phosphorous layer, which then emits visible rays, thereby forming a desired image on a screen.

In general, in forming barrier walls of a rear plate of a PDP, the barrier walls are preliminary formed and are then baked, as disclosed in Japanese Patent Laid-Open Nos. P9-283018 and P9-102275.

When a PDP has been manufactured by attaching a conventional rear plate as described above to a front plate, the PDP has deteriorated electrical and optical properties due to characteristics of the manufacturing method thereof.

## Disclosure of the Invention

Therefore, the present invention has been made in view of the above-mentioned problems, and it is an object of the present invention to provide a rear plate of a plasma display panel, which can improve electric

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and optical characteristics of a PDP.

According to an aspect of the present invention, there is provided a rear plate of a plasma display panel, the rear plate comprising: a glass substrate; electrodes formed in a shape of patterns on an upper surface of the glass substrate; a dielectric layer formed on upper surfaces of the electrode and the upper surface of the glass substrate; barrier walls formed in a shape of a pattern through etching on an upper surface of the dielectric layer; and phosphorous layers formed on side surfaces and bottom surfaces of the barrier walls, wherein: each of the electrodes has a thickness of 2 to 8 µm and a specific resistance of 1.0  $\times$  10<sup>-6</sup> to 5.0  $\times$  10<sup>-6</sup>  $\Omega$ cm; the dielectric layer is made from a first mixture which includes a first filler and at least one glass powder selected from among a first glass powder and a second glass powder, the first glass powder including PbO of 30 to 80 wt%, ZnO of 0 to 20 wt%,  $SiO_2$  of 0 to 20 wt%,  $B_2O_3$  of 5 to 40 wt%,  $Al_2O_3$  of 0 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 5 BaO+CaO+MgO+SrO of 0 to 5 wt%, the second glass powder including  $Bi_2O_3$  of 36 to 84 wt%,  $B_2O_3$  of 5 to 28 wt%, PbO of 0 to 46 wt%, ZnO of 0 to 30 wt%, Al<sub>2</sub>O<sub>3</sub> of 0 to 13 wt%,  $SiO_2$  of 0 to 10 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 5 wt%, and BaO+CaO+MgO+SrO of 0 to 3 wt%, each of the first and second glass powders having an average particle diameter of 1 to 10  $\mu m,\ a$  softening temperature of 390 to 550  $^{\circ}$ C, and a thermal expansive coefficient of 63  $\times$  $10^{-7}$  to 83  $\times$   $10^{-7}/^{\circ}$ C, the first filler having an average

particle diameter of 0.01 to 10 µm, the dielectric layer having a dielectric constant of 8 to 20, reflectance of 50 to 80%, an etching rate of 0.01 to µm/min with respect to inorganic acid, thickness of 10 to 30 µm; the barrier walls are made 5 from a second mixture which includes a second filler, organic material, additives, and at least one glass powder selected from the group consisting of a third, fourth, and fifth glass powders, the third glass powder 10 including ZnO of 0 to 48 wt%, SiO2 of 0 to 21 wt%, B2O3 of 25 to 56 wt%,  $Al_2O_3$  of 0 to 12 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 38 wt%, and BaO+CaO+MgO+SrO of 0 to 15 wt%, the fourth glass powder including PbO of 25 to 65 wt%, ZnO of 0 to 35 wt%,  $SiO_2$  of 0 to 26 wt%,  $B_2O_3$  of 0 to 30 15 wt%, Al<sub>2</sub>O<sub>3</sub>+SnO<sub>2</sub> of 0 to 13 wt%, Na<sub>2</sub>O+K<sub>2</sub>O+Li<sub>2</sub>O of 0 to 19 wt%, BaO of 0 to 26 wt%, and CaO+MgO+SrO of 0 to 13 wt%, the fifth glass powder including PbO of 35 to 55 wt%,  $B_2O_3$  of 18 to 25 wt%, ZnO of 0 to 35 wt%, BaO of 0  $SiO_2+Al_2O_3+SnO_2$  of 16 wt%, 0 to to 20  $CoO+CuO+MnO_2+Fe_2O_3$  of 0 to 15 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 19 wt%, and CaO+MgO+SrO of 0 to 13 wt%, the third glass powder having a softening temperature of 460 to 630 °C, a thermal expansive coefficient of  $64 \times 10^{-7}$  to  $105 \times 10^{-7}$  $^{7}/^{\circ}$ C, and an average particle diameter of 0.5 to 17  $\mu$ m, each of the fourth and fifth glass powders having a 25 softening temperature of 390 to 550 °C, a thermal expansive coefficient of  $63 \times 10^{-7}$  to  $110 \times 10^{-7}/^{\circ}$ C, and an average particle diameter of 0.5 to 17  $\mu m$ , second filler having an average particle diameter of

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0.01 to 10  $\mu\text{m}$ , the barrier walls being formed with a height of 100 to 180 µm by attaching a barrier wall layer formed in a shape of green tapes to an upper surface of the dielectric layer, firing the barrier wall layer together with the dielectric layer at a temperature between 400°C and 700 °C, and then etching the barrier wall layer, the barrier wall layer having a dielectric constant of 5 to 18, a reflectance of 40 to 80%, an etching rate of 1.0 to 50.0 μm/min with respect to inorganic acid; each of the phosphorous layers has a thickness of 10 to 50  $\mu m$ ; and a difference between the thermal expansive coefficients of the dielectric layer and the barrier wall layer has a percentage between 0 10 %, and a difference between the softening temperatures of the dielectric layer and the barrier wall layer has a value between 0 and 20 °C.

According to another aspect of the present invention, there is provided a rear plate of a plasma display panel, the rear plate comprising: a glass substrate; electrodes formed in a shape of patterns on an upper surface of the glass substrate; a dielectric layer formed on upper surfaces of the electrode and the upper surface of the glass substrate; barrier walls formed in a shape of a pattern through etching on an upper surface of the dielectric layer; and phosphorous layers formed on side surfaces and bottom surfaces of the barrier walls, wherein: each of the electrodes has a thickness of 2 to 8  $\mu m$  and a specific resistance of 1.0  $\times$  10<sup>-6</sup> to 5.0  $\times$  10<sup>-6</sup>  $\Omega cm$ ; the dielectric layer is

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made from a first mixture which includes a first filler, organic material, additives, and at least one glass powder selected from among a first glass powder and a second glass powder, the first glass powder including PbO of 30 to 80 wt%, ZnO of 0 to 20 wt%, SiO2 of 0 to 20 wt%,  $B_2O_3$  of 5 to 40 wt%,  $Al_2O_3$  of 0 to 12 wt%, Na<sub>2</sub>O+K<sub>2</sub>O+Li<sub>2</sub>O of 0 to 5 wt%, and BaO+CaO+MgO+SrO of 0 to 5 wt%, the second glass powder including Bi2O3 of 36 to 84 wt%,  $B_2O_3$  of 5 to 28 wt%, PbO of 0 to 46 wt%, ZnO of 0 to 30 wt%,  $Al_2O_3$  of 0 to 13 wt%,  $SiO_2$  of 0 to 10 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 5 wt%, and BaO+CaO+MqO+SrOof 0 to 3 wt%, each of the first and second glass powders having an average particle diameter of 1 to 10 a softening temperature of 390 to 550 °C, and a thermal expansive coefficient of  $63 \times 10^{-7}$  to  $83 \times 10^{-7}$ <sup>7</sup>/°C, the first filler having an average particle diameter of 0.01 to 10 µm, the dielectric layer having a dielectric constant of 8 to 20, a reflectance of 50 to 80%, an etching rate of 0.01 to 1.0 µm/min with respect to inorganic acid, and a thickness of 10 to 30  $\mu\text{m}$ , the dielectric layer being formed in a shape of a green tape and then attached to upper surfaces of the electrodes; the barrier walls are made from a second mixture which filler, includes а second organic material, additives, and at least one glass powder selected from the group consisting of a third, fourth, fifth glass powders, the third and glass including ZnO of 0 to 48 wt%,  $SiO_2$  of 0 to 21 wt%,  $B_2O_3$ of 25 to 56 wt%,  $Al_2O_3$  of 0 to 12 wt%,  $Na_2O+K_2O+Li_2O$  of 0

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to 38 wt%, and BaO+CaO+MgO+SrO of 0 to 15 wt%, the fourth glass powder including PbO of 25 to 65 wt%, ZnO of 0 to 35 wt%,  $SiO_2$  of 0 to 26 wt%,  $B_2O_3$  of 0 to 30 wt%, Al<sub>2</sub>O<sub>3</sub>+SnO<sub>2</sub> of 0 to 13 wt%, Na<sub>2</sub>O+K<sub>2</sub>O+Li<sub>2</sub>O of 0 to 19 wt%, BaO of 0 to 26 wt%, and CaO+MgO+SrO of 0 to 13 wt%, the fifth glass powder including PbO of 35 to 55 wt%,  $B_2O_3$  of 18 to 25 wt%, ZnO of 0 to 35 wt%, BaO of 0 16 wt%,  $SiO_2+Al_2O_3+SnO_2$ of 0 to  $CoO+CuO+MnO_2+Fe_2O_3$  of 0 to 15 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 19 wt%, and CaO+MgO+SrO of 0 to 13 wt%, the third glass powder having a softening temperature of 460 to 630 °C, a thermal expansive coefficient of  $64 \times 10^{-7}$  to  $105 \times 10^{-7}$  $^{7}/^{\circ}C$ , and an average particle diameter of 0.5 to 17  $\mu m$ , each of the fourth and fifth glass powders having a softening temperature of 390 to 550 °C, a thermal expansive coefficient of  $63 \times 10^{-7}$  to  $110 \times 10^{-7}$ /°C, and an average particle diameter of 0.5 to 17  $\mu m$ , second filler having an average particle diameter of 0.01 to 10  $\mu m$ , the barrier walls being formed with a height of 100 to 180 µm by attaching a barrier wall layer formed in a shape of green tapes to an upper surface of the dielectric layer, firing the barrier wall layer together with the dielectric layer at a temperature between 400°C and 700 °C, and then etching the barrier wall layer, the barrier wall layer having a dielectric constant of 5 to 18, a reflectance of 40 to 80%, and an etching rate of 1.0 to 50.0  $\mu$ m/min with respect to inorganic acid; each of the phosphorous layers has a thickness of 10 to 50 µm; and a difference

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between the thermal expansive coefficients of the dielectric layer and the barrier wall layer has a percentage between 0 and 10 %, and a difference between the softening temperatures of the dielectric layer and the barrier wall layer has a value between 0 and 20 °C.

According to still another aspect of the present invention, there is provided a rear plate of a plasma display panel, the rear plate comprising: a glass substrate; electrodes formed in a shape of patterns on an upper surface of the glass substrate; a dielectric layer formed on upper surfaces of the electrode and the upper surface of the glass substrate; barrier walls formed in a shape of a pattern through etching on an upper surface of the dielectric layer; and phosphorous layers formed on side surfaces and bottom surfaces of the barrier walls, wherein: each of the electrodes has a thickness of 2 to 8  $\mu m$  and a specific resistance of  $1.0 \times 10^{-6}$  to  $5.0 \times 10^{-6}$   $\Omega$ cm; the dielectric layer is made from a first mixture which includes a first filler, organic material, additives, and at least one glass powder selected from among a first glass powder and a second glass powder, the first glass powder including PbO of 30 to 80 wt%, ZnO of 0 to 20 wt%, SiO2 of 0 to 20 wt%,  $B_2O_3$  of 5 to 40 wt%,  $Al_2O_3$  of 0 to 1/2wt%, Na<sub>2</sub>O+K<sub>2</sub>O+Li<sub>2</sub>O of 0 to 5 wt%, and BaO+CaO+MgO+SrO of 0 to 5 wt%, the second glass powder including  $\mathrm{Bi}_2\mathrm{O}_3$  of 36 to 84 wt%, B<sub>2</sub>O<sub>3</sub> of 5 to 28 wt%, PbO of 0 to 46 wt%, ZnO of 0 to 30 wt%,  $Al_2O_3$  of 0 to 13 wt%,  $SiO_2$  of 0 to 10 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 5 wt%, and BaO+CaO+MgO+SrO

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of 0 to 3 wt%, each of the first and second glass powders having an average particle diameter of 1 to 10  $\mu\text{m}$ , a softening temperature of 390 to 550 °C, and a thermal expansive coefficient of 63  $\times$  10<sup>-7</sup> to 83  $\times$  10<sup>-</sup> <sup>7</sup>/°C, the first filler having an average particle 5 diameter of 0.01 to 10  $\mu\text{m},$  the dielectric layer having a dielectric constant of 8 to 20, a reflectance of 50 to 80%, an etching rate of 0.01 to 1.0  $\mu\text{m/min}$  with respect to inorganic acid, and a thickness of 10 to 30 10  $\mu\text{m}$ , the dielectric layer being formed in a shape of a green tape; the barrier walls are made from a second mixture which includes a second filler, organic additives, and at least one glass powder material, selected from the group consisting of a third, fourth, fifth glass powders, the third glass powder and including ZnO of 0 to 48 wt%,  $SiO_2$  of 0 to 21 wt%,  $B_2O_3$ of 25 to 56 wt%,  $Al_2O_3$  of 0 to 12 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 38 wt%, and BaO+CaO+MgO+SrO of 0 to 15 wt%, the fourth glass powder including PbO of 25 to 65 wt%, ZnO of 0 to 35 wt%,  $SiO_2$  of 0 to 26 wt%,  $B_2O_3$  of 0 to 30 wt%,  $Al_2O_3+SnO_2$  of 0 to 13 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 19 wt%, BaO of 0 to 26 wt%, and CaO+MgO+SrO of 0 to 13 wt%, the fifth glass powder including PbO of 35 to 55 wt%,  $B_2O_3$  of 18 to 25 wt%, ZnO of 0 to 35 wt%, BaO of 0 to 16 wt%,  $SiO_2+Al_2O_3+SnO_2$  of 0 to  $CoO+CuO+MnO_2+Fe_2O_3$  of 0 to 15 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 19 wt%, and CaO+MgO+SrO of 0 to 13 wt%, the third glass powder having a softening temperature of 460 to 630 °C, a thermal expansive coefficient of 64  $\times$  10<sup>-7</sup> to 105  $\times$  10<sup>-</sup>

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 $^{7}/^{\circ}\text{C}$ , and an average particle diameter of 0.5 to 17  $\mu\text{m}$ , each of the fourth and fifth glass powders having a softening temperature of 390 to 550 °C, expansive coefficient of 63  $\times$  10<sup>-7</sup> to 110  $\times$  10<sup>-7</sup>/°C, and an average particle diameter of 0.5 to 17 second filler having an average particle diameter of 0.01 to 10  $\mu\text{m};$  each of the phosphorous layers has a thickness of 10 to 50  $\mu m$ ; and a difference between the thermal expansive coefficients of the dielectric layer and the barrier wall layer has a percentage between 0 and a difference between the softening 10 왕. temperatures of the dielectric layer and the barrier wall layer has a value between 0 and 20 °C, wherein a barrier wall layer formed in a shape of green tapes, which has a dielectric constant of 5 18, reflectance of 40 to 80%, and an etching rate of 1.0 to 50.0 μm/min with respect to inorganic acid. integrated with the dielectric layer to form lamination of dielectric layer/ barrier wall layer, and the lamination of dielectric layer/ barrier wall layer is attached to the upper surfaces of the electrodes and the glass substrate, is baked at a temperature between 400°C and 700 °C, and is then etched, so that the barrier walls are formed with a height of 100 to 180 μm.

Herein, each of the barrier walls has at least two different layers having different etching rates with respect to inorganic acid.

In a rear plate of a plasma display panel

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according to the present invention, a dielectric layer or a barrier wall layer is formed by forming slurry in a tape of a green tape and then attaching the green tape to upper surfaces of electrodes and a glass substrate. Therefore, a PDP employing a rear plate according to the present invention has superior electric and optical characteristics.

## Brief Description of the Drawings

- The foregoing and other objects, features and advantages of the present invention will become more apparent from the following detailed description when taken in conjunction with the accompanying drawings in which:
- FIG. 1 is a sectional view of a rear plate of a plasma display panel according to a first embodiment of the present invention;
  - FIG. 2 is a sectional view of a rear plate of a plasma display panel according to a second embodiment of the present invention; and
  - FIG. 3 is a sectional view of a rear plate of a plasma display panel according to a third embodiment of the present invention.

# 25 Best Mode for Carrying Out the Invention

Hereinafter, a rear plate of a plasma display panel according to preferred embodiments of the present invention will be described in detail with reference to the accompanying drawings.

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FIG. 1 is a sectional view of a rear plate of a plasma display panel according to a first embodiment of the present invention.

As shown in FIG. 1, a rear plate 100 of a plasma display panel (hereinafter, referred to as "PDP") according to the present embodiment includes a glass substrate 110, electrodes 120 formed in a shape of a pattern and spaced at a predetermined interval from each other on an upper surface of the glass substrate 110, a dielectric layer 130 formed on upper surfaces of the electrode 120 and the upper surface of the glass substrate 110, barrier walls 140 formed on an upper surface of the dielectric layer 130 and spaced a predetermined interval from each other, and phosphorous layers 150 formed on side surfaces and bottom surfaces of the barrier walls 140.

Since the barrier walls 140 is formed through etching, the barrier walls must have a proper etching rate for etching solution and the electrodes 120 and the dielectric layer 130 must have resistance to the etching solution. In order to meet the requirements described above, each of the functional layers of the rear plate 100 according to the present embodiment has a specific composition, which will be described hereinafter.

## First embodiment

In the rear plate 100 according to the first embodiment of the present invention, the dielectric

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layer 130 is formed by a screen printing method, the barrier walls are formed in a shape of green tapes, and then the dielectric layer 130 and the barrier walls are simultaneously baked. This process will be described in detail hereinafter.

The electrodes 120 formed on the upper surface of the glass substrate has a thickness of  $2\sim 8\,\mu\mathrm{m}$ . photosensitive paste for the electrodes, which has a specific resistance of 2.5 x  $10^{-6}$  to 4.0 x  $10^{-6}\Omega$  cm, is screen-printed on the upper surface of the glass substrate 110, is dried, and is then subjected to photolithography and firing, thereby forming electrodes 120. When the electrodes have a specific resistance of lower than 2.5  $\times$  10<sup>-6</sup>, the low resistance enables the electrodes to process an address signal without noise. However, the electrodes must be made from gold or silver with high purity, which increases the manufacturing cost for the electrodes. In contrast, when the electrodes have a specific resistance of larger than 4 x  $10^{-6}~\Omega$  cm, such problems as increase of an address driving voltage are caused.

The dielectric layer 130 is made from mixture of a first filler and at least one glass powder selected from among a first glass powder and a second glass powder. The dielectric layer 130 has a thickness of 10 to 30  $\mu m\,$ 

The first glass powder comprises PbO of 30 to 80 wt%, ZnO of 0 to 20 wt%, SiO<sub>2</sub> of 0 to 20 wt%, B<sub>2</sub>O<sub>3</sub> of 5 to 40 wt%, Al<sub>2</sub>O<sub>3</sub> of 0 to 12 wt%, Na<sub>2</sub>O+K<sub>2</sub>O+Li<sub>2</sub>O of 0 to 5

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wt%, and BaO+CaO+MgO+SrO of 0 to 5 wt%. The second glass powder comprises  $Bi_2O_3$  of 36 to 84 wt%,  $B_2O_3$  of 5 to 28 wt%, PbO of 0 to 46 wt%, ZnO of 0 to 30 wt%,  $Al_2O_3$  of 0 to 13 wt%,  $SiO_2$  of 0 to 10 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 5 wt%, and BaO+CaO+MgO+SrO of 0 to 3 wt%. The first filler includes at least one selected from the group consisting of  $TiO_2$ ,  $ZrO_2$ ,  $ZnO_3$ ,  $Al_2O_3$ , BN, mullite, and MgO.

Each of the first and second glass powders has a softening temperature of 390 to 550 °C. When their softening temperature is smaller than 390 °C, the dielectric layer 130 may flow in steps of firing the phosphorous layers and attaching the front plate and the rear plate of the PDP to each other after the barrier walls 140 are formed, thereby deteriorating correctness in the measurements of the PDP. In contrast, when the softening temperature is larger than 550 °C, the firing temperature of the dielectric layer 130 becomes so high as to change the measurements of the glass substrate 110, thereby causing it difficult to control the measurements of the glass substrate 110.

It is preferred that each of the first and second glass powders has an average particle diameter of 1 to 10  $\mu m$ . When each of the first and second glass powders has an average particle diameter of less than 1  $\mu m$ , they have a reduced workability. In contrast, when each of the first and second glass powders has an average particle diameter of more than 10  $\mu m$ , the dielectric layer 130 is not sufficiently compacted while being

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baked, so that the dielectric layer 130 may be porous.

Also, each of the first and second glass powders preferably has a thermal expansive coefficient of 63  $\times$  $10^{-7}$  to 83 ×  $10^{-7}$ /°C. When the thermal expansive coefficient is smaller than  $63 \times 10^{-7}$ /°C, the glass substrate 110 may be convexly bent. In contrast, when the thermal expansive coefficient is larger than 83  $\times$  $10^{-7}/^{\circ}\text{C}$ , the glass substrate 110 may be concavely bent or the surface of the dielectric layer 130 may crack. However, even when each of the first and second glass powders preferably has a thermal expansive coefficient of 95  $\times$  10<sup>-7</sup>/°C, the thermal expansive coefficient can be lowered to 83  $\times$  10<sup>-7</sup>/°C by mixing a proper amount of the first filler with the first and second glass powders. Therefore, it will do if each of the first and second glass powders preferably has a thermal expansive coefficient of 63  $\times$  10<sup>-7</sup> even up to 95  $\times$  10<sup>-7</sup>/°C.

It is preferred that each of the first and second glass powders has a dielectric constant of 11 to 26. When the dielectric constant of the dielectric layer 130 is smaller than 11, it is difficult to transfer a signal the electrode 120 to a discharge space defined by the barrier walls 140. In contrast, when the dielectric constant of the dielectric layer 130 larger than 26, the PDP has too slow a response speed when the PDP is driven. Meanwhile, when each of the first and second glass powders has a dielectric constant of at least 6, the dielectric constant of the dielectric layer 130 can be elevated up to 11 by means

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of the first filler. Therefore, it is also preferred that each of the first and second glass powders has a dielectric constant of 6 to 26.

The first filler preferably has an average particle diameter of 0.01 to 10  $\mu m\,.$ Further, preferred that a volumetric ratio of the first filler with respect to the glass powder in the dielectric layer is 0.05 to 0.67. When the volumetric ratio is than 0.05. the dielectric layer 130 has reflectance of at most 50%, thereby preventing the PDP from employing a dielectric layer having a reflectance of at least 50% which is necessary in order to enable the PDP to have an improved brightness. Further, in the case in which the volumetric ratio is more than 0.67, when the softening temperature of the glass powder is low, the dielectric constant is high and thus the response seed is slow. In contrast, when the softening temperature of the glass powder is high, the degree of firing of the dielectric layer 130 deteriorates, that it is difficult for the dielectric layer 130 to have a resistance to etching and the dielectric layer 130 has a dielectric constant of at most 11.

The dielectric layer 130 having the ingredients as described above has a dielectric constant of 8 to 20, a reflectance of 50 to 80%, and an etching rate of 0.1 to 1.0  $\mu$ m/min with respect to inorganic acid. When the etching rate of the dielectric layer 130 is smaller than 0.1  $\mu$ m/min, the firing temperature of the dielectric layer 130 may rise above 700 °C, thereby

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deforming the glass substrate 110. In contrast, when the etching rate is larger than 1.0  $\mu$ m/min, the powder has a reduced resistance to etching, so that even the dielectric layer 130 and the electrodes 120 may be etched when the barrier wall 140 is etched. When the electrode 120 has been damaged by etching, the electric resistance of the electrode 120 increases.

The first filler can be classified into two kinds of oxides, which have weak and strong chemical durability with respect to acid-based etching solution, respectively. The first kind of oxide having a weak chemical durability with respect to acid-based etching solution reacts with glass powder while it is baked, thereby deteriorating the chemical durability of the reacted glass powder. In contrast, the second kind of oxide having a strong chemical durability with respect to acid-based etching solution reacts with glass powder while it is baked, thereby increasing the chemical durability of the reacted glass powder.

Further, when the dielectric layer 130 includes too much first filler, quantity of the first filler, which does not react with the oxide, increases, so that firing strength deteriorates. Therefore, preferred that a ratio of volume of the first filler with respect to volume of the glass powder in the dielectric layer 130 is not larger than 0.67. The less the quantity of the first filler is, the more the white degree of the dielectric layer 130 deteriorates. However, since some PDPs may have a dielectric layer

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130 with an unlimited white degree, it is unnecessary to define a lower limit of the ratio of volume of the first filler with respect to volume of the glass powder in the dielectric layer 130.

The dielectric layer 130 may have defect due to either repetition of printing and drying processes or screen plate making. The defect due to screen plate making include irregular thickness of meshes, uniform surface state of meshes, stains of meshes, etc., which may cause defect such as pinholes or height difference on the dielectric layer 130. Further, material of the dielectric layer 130 may be insufficiently filled under end portions of the electrodes 120 due to a curl phenomenon in which the end portions of the electrodes 120 formed through photolithography and firing are curled up while they are being baked. Then, bubbles may be generated between the electrodes 120 and the dielectric layer 130 to the resistance to voltage, thereby insulation breaking, while a PDP operates. Therefore, in forming the dielectric layer 130, either a printing method or a green tape attachment method, which will be described later, must be employed according to material or characteristics of its shape.

The barrier walls 140 are formed on the upper surface of the dielectric layer 130. Specifically, a slurry is formed in a shape of green tapes having a predetermined thickness and is then attached to the upper surface of the dielectric layer 130. Then, the

attached green tapes are subjected to photolithography and etching, thereby the barrier walls 140 having a shape of patterns.

The barrier wall 140 is made in a shape of green tapes by adding organic material and additive to mixture of a second filler and at least one glass powder selected from the group consisting of the third, fourth, and fifth glass powders.

The third glass powder comprises ZnO of 0 to 48 wt%,  $\mathrm{SiO_2}$  of 0 to 21 wt%,  $\mathrm{B_2O_3}$  of 25 to 56 wt%,  $\mathrm{Al_2O_3}$  of 10 0 to 12 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 38 wt%, BaO+CaO+MgO+SrO of 0 to 15 wt%. The fourth glass powder comprises PbO of 25 to 65 wt%, ZnO of 0 to 35 wt%, SiO2 of 0 to 26 wt%,  $B_2O_3$  of 0 to 30 wt%,  $Al_2O_3+SnO_2$  of 0 to 13 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 19 wt%, BaO of 0 to 26 15 wt%, and CaO+MgO+SrO of 0 to 13 wt%. The fifth glass powder comprises PbO of 35 to 55 wt%,  $B_2O_3$  of 18 to 25 wt%, ZnO of 0 to 35 wt%, BaO of 0 to 16 wt%,  $SiO_2+Al_2O_3+SnO_2$  of 0 to 9 wt%,  $CoO+CuO+MnO_2+Fe_2O_3$  of 0 to 15 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 19 wt%, and CaO+MgO+SrO of 20 0 to 13 wt%. The second filler includes at least one selected from the group consisting of TiO2, ZrO2, ZnO,  $Al_2O_3$ , BN, mullite, and MgO.

Herein, the third glass powder has a softening temperature of 460 to 630 °C, and each of the fourth and fifth glass powders has a softening temperature of 390 to 550 °C. In the case where the softening temperature is smaller than 460 °C and 390 °C, respectively, when the phosphorous layers 150 are baked after the barrier

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walls 140 are formed or after the front and rear plates are attached to each other, the barrier walls 140 may be deformed so that the barrier walls 140 may have much irregular heights and their upper portions may have much irregular widths. In contrast, in a case where the softening temperature is larger than 630 °C and 550 °C, respectively, the firing temperature of the barrier wall 140 increases, thereby causing it difficult to control the measurements of the glass substrate 110.

The third glass powder has a thermal expansive coefficient of 64  $\times$  10<sup>-7</sup> to 105  $\times$  10<sup>-7</sup>/°C, and each of the fourth and fifth glass powders preferably has a thermal expansive coefficient of 63  $\times$  10<sup>-7</sup> to 110  $\times$  10<sup>-</sup> <sup>7</sup>/°C. When the thermal expansive coefficient is smaller than 63  $\times$  10<sup>-7</sup>/°C and 63  $\times$  10<sup>-7</sup>/°C, respectively, the glass substrate 110 may be convexly bent. In contrast, when the thermal expansive coefficient is larger than  $105 \times 10^{-7}/^{\circ}$ C or  $110 \times 10^{-7}/^{\circ}$ C, respectively, the glass substrate 110 may be concavely bent or the surface of the glass substrate 110 may crack. However, since the thermal expansive coefficient can be changed adjusting the amount of the filler in the barrier wall 140, each of the third, fourth, and fifth glass powders may preferably have a thermal expansive coefficient of  $63 \times 10^{-7}$  even up to  $110 \times 10^{-7}$ /°C.

Each of the third, fourth, and fifth glass powders has an average particle diameter of 0.5 to 17  $\mu m.$  When the glass powder has an average particle diameter of smaller than 0.5  $\mu m,$  it is difficult to make paste for

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the barrier wall from the glass powder. In contrast, when the conductive metal powder has an average particle diameter of larger than 17  $\mu m$ , it is difficult to enable the barrier walls to be sufficiently compact through firing after forming the barrier walls.

Each of the third, fourth, and fifth glass powders has a dielectric constant of 5 to 20. In the case where the dielectric constant is smaller than 5, a drive voltage characteristic is deteriorated when a manufactured PDP is driven. In contrast, in the case where the dielectric constant is larger than 20, crosstalk and erroneous discharge may occur when the manufactured PDP is driven.

Further, the second filler has an average particle diameter of at most 10  $\mu m$ . Also, a volumetric ratio of the first filler with respect to the glass powder for the barrier walls is 0.05 to 0.67, which will be described later.

Organic material and additive are added to the 20 material for the barrier walls as described above, so as to form a slurry with a viscosity of 500 to 40000 cP (centi-poise) shape of green tapes, in a forming preliminary barrier walls. Then. preliminary barrier walls in a shape of green tapes are attached to the upper surface of the dielectric layer 25 130 through lamination, and are then simultaneously baked together with the dielectric layer 130 at a temperature above 400 °C. Herein, it is preferred that the preliminary barrier walls in a shape of green tapes

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have a thickness of 100 o 180  $\mu m\,.$ 

In order to simultaneously bake the dielectric layer 130 and the barrier walls, a difference between the thermal expansive coefficients of them must have a value of at most 10%, and a difference between the softening temperatures of them must have a value of at most 20°C. If the difference between the thermal expansive coefficients of them has a value larger than 10%, the dielectric layer 130 and the barrier walls may be separated from each other, thereby allowing bubbles formed between them, when they have been simultaneously baked. Further, the glass substrate 110 may be bent due to the difference between the thermal expansive coefficients of them, thereby preventing the rear plate from being attached to the front plate.

Further, when the difference between the softening temperatures of them has a value larger than 20°C, end portions of the dielectric layer 130 and the barrier walls may be curled up or may come off, thereby allowing bubbles to be formed between them. When too bubbles exist in an interface between dielectric layer 130 and the barrier walls, each of the dielectric layer 130 and the barrier walls may have a sparse internal structure, thereby having fragility and deteriorated strength. Further, when too many bubbles exist in an interface between dielectric layer 130 and the barrier walls, the bubbles may come into the dielectric layer 130 and the barrier walls while the dielectric layer 130 and the barrier

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walls are baked, so that the dielectric layer 130 and the barrier walls may have deteriorated properties and insulation breaking may occur while a PDP operates.

In order to prepare the material for the barrier walls in a form of slurry, organic materials and additives are necessary. The organic materials include a binding agent which provides strength to the barrier walls, a solvent which dissolves the material of the barrier walls and provides fluidity necessary and casting to the barrier walls, milling and a plasticizer which improves workability of the barrier The additives include a defoaming agent for walls. reducing generation of bubbles, a dispersing agent for aiding dispersion of inorganic material, dyes, lubricating oil.

The binding agent includes at least one selected the group consisting of Polyvinyl butyral, Polyvinyl alcohol, Polyvinyl acetate, Poly Metaacrylate, Poly ethyl acrylate, Poly acrylic acid, Cellulose, Hydroxyethyl cellulose, Methyl cellulose, Carboxymethyl cellulose, Acrylic ester, and Ammonium Polyacrylate. The solvent includes at least selected from the one group consisting of alcohol, n-Butyl alcohol, Toluene, Water, alcohol, n-Propyl alcohol, Isopropyl alcohol, Ethylene Glycol, Benzaldehide, Ethylacetate, Cyclohexane, Isopropyl acetate, n-Octyl alcohol, Benzyl alcohol, Glycerol, Acetone, Methyl Ethyl Keton, Propionic acid, n-Octanoic acid, n-Hexane, O-Xylene, MIBK, Xylene, and

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Butanyl. The plasticizer includes at least one selected from the group consisting of Water, Ethylene Glycol, Diethylene Glycol, Tetraethylene glycol, Glycerine, Dimethyl phtalate, Dibutyl phtalate, Benzyl butyl phthalate, poly propylene glycol, Phosphate, Phthalate, Glycol ether, and Polyethylen glycol.

As the additives, typical additives are used.

The binding agent must experience a complete thermal decomposition through the drying and firing Ιf the binding agent is not thermally decomposed, carbon residue may exist in the barrier thereby greatly decreasing an insulation strength of the barrier walls. The solvent is selected in consideration of viscosity of slurry and drying speed according to the thickness of the green tapes and casting, solubility and speed of dissolution adhesive agent and other organic materials, etc. The plasticizer must be selected in consideration compatibility of the plasticizer with the binding agent. If a plasticizer shows an incompatibility with respect to the binding agent according to temperature increase, the plasticizer escapes out of the green tapes during the drying process, so that the green tapes have fragility. The organic material is selected in consideration of properties such as viscosity in milling, viscosity in casting, thickness of the green tapes, strength of the green tapes, percentage of elongation, and workability. When the quantity of the organic material is too much, defoamation process must

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be performed for long time. In contrast, when the quantity of the organic material is too little, an efficiency of milling for preparing the slurry deteriorates.

As shown in FIG. 2, each barrier wall 245 may include a plurality of wall layers 245<sub>-1</sub>, 245<sub>-2</sub>,....245<sub>(n-1)</sub>, 245<sub>-n</sub> which are prepared from different materials having different etching rates to inorganic acid. Herein, if the multiple wall layers 245<sub>-1</sub>, 245<sub>-2</sub>,..., 245<sub>-(n-1)</sub>, 245<sub>-n</sub> constituting the barrier wall 245 are named first, second,..., (n-1)<sup>th</sup>, and n<sup>th</sup> wall layers, respectively, the (n-1)<sup>th</sup> wall layer has an etching rate with respect to inorganic acid, which is larger than or equal to that of the n<sup>th</sup> wall layer. As a result, when the barrier wall 245 is formed through etching, side surfaces of the barrier wall 245 can be formed nearly vertically, thereby forming a rectangular discharge space.

Further, each of the wall layers 245-1, 245-2,..., 245-(n-1), 245-n must have a thickness corresponding to 5% to 95% of the entire thickness of the barrier wall 245. If any of the wall layers has a thickness, which is either smaller than 5% or larger than 95% of the entire thickness of the barrier wall 245, the thickness of that wall layer is too small or too large to have an effect by the adjustment of etching rate as described above, thereby making it useless to form the barrier wall 245 from at least two kinds of different materials.

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When barrier walls are formed in a shape of green tapes from mixture in which organic material additives are added to the material of the barrier composition and properties which has the described above according to the first embodiment barrier walls invention, the present dielectric constant of 5 to 18, a reflectance of 40 to 80%, and an etching rate of 1.0 to 50.0  $\mu$ m/min.

Further, the phosphorous layers 150 include red, green, and blue phosphorous layers formed on side and bottom surfaces of the barrier walls 140, each of the phosphorous layers having a thickness of at least 10  $\mu m$ .

### 15 Second embodiment

FIG. 2 is a sectional view of a rear plate of a plasma display panel according to the second embodiment of the present invention.

As shown, a dielectric layer 230 and barrier walls 245 each are arranged in a shape of green tapes, the dielectric layer 230 is formed on upper surfaces of an electrode 220 and a glass substrate 210, and then the barrier walls 245 are formed on an upper surface of the dielectric layer 230, so that a rear plate 200 according to the second embodiment of the present invention is completed.

The electrode 220 according to the second embodiment is the same as the electrode according to the first embodiment, and the dielectric layer 230

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according to the second embodiment is made from the same material as that of the dielectric layer 130 according to the first embodiment. However, in forming dielectric layer 230 according to the embodiment, organic material and additives are added to material of the dielectric layer 130 according to the first embodiment, which is then formed in a shape of green tapes and attached to the upper surfaces of the electrode 220 and the glass substrate 210. Further, the barrier walls 245 according to the second embodiment is formed on the upper surface of the dielectric layer 230 in the same manner as that according to the first embodiment, and the dielectric layer 230 and barrier walls 245 are simultaneously baked temperature above 400°C as those according to the first embodiment.

The other constructions according to the second embodiment are the same as those according to the first embodiment.

#### 20 Third embodiment

FIG. 3 is a sectional view of a rear plate of a plasma display panel according to the third embodiment of the present invention.

As shown, composition and characteristics of each functional layer of a rear plate according to the third embodiment of the present invention is the same as the composition and characteristics of each functional layer of the rear plate according to the second embodiment of the present invention. In description of

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only the differences between them, a dielectric layer 330 and barrier walls 345 are prepared in a shape of green tapes having a thickness of 10 to 30 µm and 100 to 180 µm, respectively, and are integrated with each other. Thereafter, the dielectric layer 330 is attached to upper surfaces of electrodes 320 and a glass substrate 310. Then, they are baked at a temperature above 400°C, so that the dielectric layer 330 and the barrier walls 345 are completed.

The other constructions according to the third embodiment are the same as those according to the second embodiment.

The etching rate described in the first, second, and third embodiments is defined by an equation, etching rate = {(M1-M2)/6.25} × 100. In this equation, M1 implies mass of a substrate having a size of 2.5 cm × 2.5 cm, on the entire surface of which material for the dielectric layer or the barrier walls has been applied and then baked. M2 implies mass of the substrate, measured after the substrate is wet-etched for two minutes, is washed for one minute by ultrasonic wave and then for one minute by flowing water, and is then dried.

Next, measured properties of each functional layer of the rear plate manufactured as described above will be described.

### Experiment 1

EPH-200TR5611 photosensitive electrode paste

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having a specific resistance of 2.7 x  $10^{-6}\Omega$  cm, made by Ink company of Japan, was applied with thickness of  $4\sim6\mu\mathrm{m}$  on an upper surface of a glass substrate by means of a polyester screen Mask of #200 mesh and was then dried for fifteen minutes at 90°C, thereby forming an electrode layer. Thereafter, the electrode layer formed on the glass substrate was exposed to light and was then developed, electrodes having a shape of patterns were formed. the exposure step, the electrode layer was exposed to light of 500 mJ emitted by a mirror reflected parallel beam illuminator (MRPBI) equipped with a mercury lamp. in the development step, Also, solution containing sodium carbonate of 0.4 wt% at a temperature of 30°C was sprayed for thirty seconds at a pressure of 0.2 Mpa, and then pure water at 25°C was sprayed for thirty seconds at a pressure of 0.1 Mpa onto the electrode substrate. Then, the electrodes dried after being developed were baked for fifteen minutes at a maximum temperature of 550°C.

A dielectric layer with a thickness of 22  $\mu m$  was formed on upper surfaces of the electrodes through screen printing using a SUS screen Mask of #200 mesh, and was then dried for ten minutes at 120°C. Table 1 shows composition of the dielectric layer.

#### Table 1

Composition of the dielectric layer according to experiment 1:

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Class		Jet						
	PbO	SiO₂	B203	Al <sub>2</sub> O <sub>3</sub>	ZnO	NaO	BaO	filler
Dielec-	43.5	16	8	2.5	29	1	,	TiO <sub>2</sub> +
tric								ZnO <sub>2</sub> +
layer			_					Al <sub>2</sub> O <sub>3</sub>

Glass powder of the dielectric layer having the composition shown in table 1 has a softening temperature of 460°C. When the dielectric layer has been baked for fifteen minutes at a maximum temperature of 530°C, the dielectric layer has a dielectric constant of 12.5, a reflectance of 70%, an etching rate of 0.5  $\mu$ m/min with respect to inorganic acid.

The barrier walls were formed in a shape of green tapes with three layers and were then laminated on the upper surface of the dielectric layer. Table 2 shows composition of each layer of the barrier walls.

Table 2

15 Composition of each layer of the barrier walls according to experiment 1:

Cl	Class Gradients of glass powder (wt%)							Filler		
ļ		PbO	ZnO	SiO <sub>2</sub>	B <sub>2</sub> O <sub>3</sub>	Al <sub>2</sub> O <sub>3</sub>	Li <sub>2</sub> O+	BaO	CaO+	j.
		!				+ZnO <sub>2</sub>	Na <sub>2</sub> O+		MgO+	
							K₂O		Sr0	
Parti-	1 <sup>st</sup>	40	22	6	18	2	12	0	1	TiO2+ZnO2
tion	layer								,	+Al <sub>2</sub> O <sub>3</sub>
wall	2 <sup>nd</sup>	41	30	5	18	2	2	0	2 :	ZrO <sub>2</sub> +Al <sub>2</sub> O <sub>3</sub>
	layer									

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3 <sup>rd</sup>	55	20	0	16	1	5	1	2	TiO <sub>2</sub> +ZrO <sub>2</sub>
layer									+Al <sub>2</sub> O <sub>3</sub>

In forming the barrier walls in a shape of green B-44 and B-48, which are binders having different molecular weights from among PolyMethyl Meta Acrylate-series (PMMA-series) binders manufactured by Rohm and Hass company, were employed, mixture of ethyl alcohol and toluene by 1:1 was employed as solvent, and dimethyl phtalate was employed as a plasticizer. Further, menhaden fish oil was employed as a dispersing agent, and stearic acid was employed as a lubricating agent. Herein, a binder of 6 wt%, a solvent of 30 wt%, a plasticizer of 8 wt%, a dispersing agnet of 1 wt%, and a lubricating agent of 0.3 wt% were added in the powder mixture of 100 wt% for the barrier walls, which glass powder and filler are mixed.

After the additives described were added, barrier walls were formed in a shape of green tapes with three layers by means of a tape caster. Then, each barrier wall was solidified to have a total thickness of 196  $\mu$ m, in which a thickness ratio of (the first layer): (the second layer): (the third layer) Thereafter, the barrier walls having a 1:(0.9):(0.8). shape of green tapes were attached to the upper surface of the dielectric layer through laminating by a roller at a temperature of 105°C and a pressure of 0.3Mpa, and were then baked together with the dielectric layer at a maximum temperature of 530°C for 15 minutes. Then, each

of the formed barrier walls were formed to have a thickness of 150  $\mu m$ .

Table 3 shows properties of the barrier walls formed as described above.

Table 3

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Measured properties of each layer of the barrier wall according to experiment 1:

			Perrinenc			i	
Cla	ass	Soften-	Thermal	Average	Dielectric	Reflection	Etching
		ing	expansive	particle	constant	ratio(%)	rate
te		temper-	coeffici-	diameter		. !	(μm/Min)
	ature		ent	( <i>μ</i> m)		4	ļ
		(°C)	(x 10 <sup>-7</sup> /℃)			:	
	1 <sup>st</sup>	40	22	6	18	2	12
Parti	layer					:	
-tion	2 <sup>nd</sup>	41	30	5	18	2	2
wall	layer					!	
	3 <sup>rd</sup>	55	20	0	16	i	5
	layer					!	

Photosensitive material was applied on the upper surfaces of the barrier walls, was exposed to light by means of a photo mask, and was then | developed. Thereafter, inorganic acid sprayed onto was developed photosensitive material at a pressure of 2  $kgf/cm^2$ , so that the barrier walls were completely formed in a shape of patterns through a selective wet Then, each barrier wall had an uppermost etching. portion having a width of 50 µm and a lowermost portion having a width of 120  $\mu$ m.

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Thereafter, red, green, and blue phosphors were printed with a thickness of 17  $\mu m$  on side and bottom surfaces of the barrier walls, thereby forming phosphorous layers covered on the barrier walls.

Table 4 shows properties of PDPs employing a rear plate according to experiment 1 and a conventional rear plate, respectively.

Table 4

Measured properties of PDPs employing a rear plate according to experiment 1 and a conventional rear

according to experiment 1 and a conventional rear plate:

Class

PDP
PDP

1 :			<del></del>
	Class	PDP	PDP
		employing	employing
1		conventional	rear plate
1		rear plate	of
			experiment 1
	Pitch	250µm	250 <i>µ</i> an
Number	of firings of rear plate	4 times	3 times
	Discharge space	100%	106%
Optical	White Peak brightness	100%	132%
properties	Color temperature(K)	8500	8802
i	Contrast	100%	128%
Electrical	Voltage margin	100%	145%
properties	Power consumption	100%	89%
:	Module efficiency	100%	125%
reliability	High temp./low temp. erroneous	No	No
	discharge		

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	vibration/drop test	No	No
		progressive	progressive
		defect	defect
Other	noise (dB)	100%	75%
properties			

As apparent from table 4, a PDP employing a rear plate according to experiment 1 of the present invention has shown improvement in comparison with a PDP employing a conventional rear plate, which includes 6% increase of discharge space, 32% increase of white brightness, 302k increase of color temperature, increase of contrast, 45% of voltage margin, decrease of power consumption, 25% increase of efficiency, and 25% decrease of noise. In table 4, "Pitch" implies a distance between centers of adjacent two barrier walls.

## Experiment 2

Electrodes in experiment 2 are the same as the electrodes in experiment 1, excepting that the firing temperature in experiment 2 is 570°C.

An electrode layer formed on a glass substrate was exposed to light and developed, so that electrodes having a shape of patterns were formed. In the exposure step, the electrode layer was exposed to light of 500 mJ emitted by a mirror reflected parallel beam illuminator equipped with a mercury lamp. Also, in the development step, solution containing sodium carbonate

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of 1'.0 wt% at a temperature of 30°C was sprayed for thirty seconds at a pressure of 0.2 Mpa, and then pure water at 30°C was sprayed for thirty seconds pressure of 0.1 Mpa onto the electrode substrate. the electrodes dried after being developed were baked for fifteen minutes at a maximum temperature of 570°C.

Thereafter, the dielectric layer was formed in a form of a green tape and was then laminated on the upper surfaces of the electrodes. Table 5 shows composition of the dielectric layer.

Table 5 Composition of the dielectric layer in experiment 2

Class			Filler					
	PbO	SiO <sub>2</sub>	B <sub>2</sub> O <sub>3</sub>	Al <sub>2</sub> O <sub>3</sub>	ZnO	NaO	BaO	
Dielectric	60	15	19	6				TiO <sub>2</sub> +ZnO <sub>2</sub> +Al <sub>2</sub> O <sub>3</sub>

Glass powder of the dielectric layer having the composition shown in table 5 has а softening temperature of 450°C. In order to prepare the dielectric layer in a shape of a green tape, poly vinyl buryral and B98 manufactured by Monsanto co., Ltd. were employed as a binder, mixture including MEK, ethyl alcohol, and n-butyl alcohol at a weight ratio of 3:1:1 employed as a solvent, dibutyl phthalate was employed as a plasticizer, and SN-9228, manufactured by Sanocof co., Ltd., was employed as a dispersing agent.

25 Herein, a binder of 6 wt%, a solvent of 30 wt%, a

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plasticizer of 1 wt%, and a dispersing agnet of 8 wt% were added in the powder mixture of 100 wt% for the dielectric layer, in which glass powder and filler are mixed.

In forming the dielectric layer, slurry including the above-mentioned additives and having a viscosity of  $8000\pm500$  cps was prepared in a form of a green tape with a thickness of 37  $\mu\text{m}$ , and was then attached to upper surfaces of the electrodes and the glass substrate through laminating by a roller at a temperature of 95°C and a pressure of 0.25Mpa.

Thereafter, the attached green tape was baked at a maximum temperature of 530°C for 15 minutes. Then, the completed dielectric layer had a dielectric constant of 18.0, a reflectance of 73%, an etching rate of 0.3 $\mu$ m/min with respect to inorganic acid.

Thereafter, barrier walls equal to those according to experiment 1 were attached to the upper surface of the dielectric layer through laminating by a roller at a temperature of 105°C and a pressure of 0.3Mpa, and were then baked together with the dielectric layer at a maximum temperature of 530°C for 15 minutes. was formed ťο have the dielectric layer thickness of 25  $\mu\text{m}$ , and each of the formed barrier walls were formed to have a thickness of 150  $\mu m$ , second, and third layers of each which the first, barrier wall have 56  $\mu m$ , 50  $\mu m$ , 44  $\mu m$ , respectively. and lowermost uppermost the widths of the Also, portions of each barrier wall, and the pitch between barrier walls were arranged to be the same as those in experiment 1.

Thereafter, phosphorous layers were formed in the same manner as that in experiment 1, excepting that each phosphorous layer was formed to have a thickness of  $14\mu\text{m}$ .

Table 6 shows properties of PDPs employing a rear plate according to experiment 2 and a conventional rear plate, respectively.

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Measured properties of PDPs employing a rear plate according to experiment 2 and a conventional rear plate:

:		Class	PDP	PDP
:			employing	employing
			conventional	rear plate
		,	rear plate	of
				experiment 2
		Pitch	250 <i>µ</i> m	250 <i>µ</i> an
	Number	of firings of rear plate	4 times	3 times
		Discharge space	100%	106%
Opti	cal	White Peak brightness	100%	130%
prope	rties	Color temperature(K)	8500	8796
	1	Contrast	100%	125%
Elect	Electrical Voltage margin		100%	137%
prope	erties Power consumption		100%	89%
	:	Module efficiency	100%	121%

reliability	High temp./low temp. erroneous	No	No
	discharge	1	
	vibration/drop test	No	No
		progressive	progressive
		defect	defect
Other	noise (dB)	100%	75%
properties			

As apparent from table 6, like the PDP employing a rear plate according to experiment 1 of the present invention, a PDP employing a rear plate according to experiment 2 of the present invention has shown improvement in electric and optical characteristics and reliability, in comparison with a PDP employing a conventional rear plate.

#### 10 Experiment 3

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Electrodes in experiment 3 are the same as the electrodes in experiment 2.

An electrode layer and a barrier wall layer were prepared in a shape of a green tape, respectively, and were then integrated with each other, thereby forming a lamination of electrode layer/barrier wall layer having a form of a green tape.

Thereafter, the lamination of electrode layer/barrier wall layer was laminated on the upper surfaces of the electrodes. Tables 7 and 8 show composition of the dielectric layer and the barrier wall layer, respectively.

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Table 7
Composition of the dielectric layer in experiment 3:

Class	Gradients of glass powder (wt%)						Filler	
,	PbO	SiO <sub>2</sub>	B <sub>2</sub> O <sub>3</sub>	Al <sub>2</sub> O <sub>3</sub>	ZnO	NaO	BaO	
Dielectric	53	13	6	12	10	0	2	TiO <sub>2</sub> +Al <sub>2</sub> O <sub>3</sub>

Glass powder of the dielectric layer having the composition shown in table 7 has a softening temperature of 535°C. In order to prepare dielectric layer in a shape of a green tape, PVB and B98 manufactured by Monsanto co., Ltd. were employed as a binder, mixture including toluene, ethanol, and nbutyl alcohol was employed as a solvent, dibutvl phthalate was employed as a plasticizer, and SN-9228, manufactured by Sanoncof co., Ltd., was employed as a dispersing agent. Herein, a binder of 12 wt%, a solvent of 20 wt%, a plasticizer of 1 wt%, and a dispersing agent; of 4 wt% were added in the powder mixture of 100 wt% for the dielectric layer, in which glass powder and filler are mixed. The solvent of 20 wt% includes toluene of 4 wt%, ethanol of 1 wt%, and n-butyl alcohol of 1 wt%, mixed therein. As a result, a dielectric layer was formed in a shape of a green tape having a viscosity of 8000±500 cps.

Next, the dielectric layer formed as described above was baked at a maximum temperature of 550°C for 15 minutes. Then, the completed dielectric layer was

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observed to have a dielectric constant of 13.2, a reflectance of 69%, an etching rate of  $0.12\mu\text{m/min}$  with respect to inorganic acid.

Table 8

Composition of the barrier wall in experiment 3:

								Filler	
Class		Gradients of glass powder (wt%)							
	PbO	ZnO	SiO <sub>2</sub>	B <sub>2</sub> O <sub>3</sub>	Al <sub>2</sub> O <sub>3</sub> +	Li <sub>2</sub> O+	BaO	CaO+	
					ZnO <sub>2</sub>	Na <sub>2</sub> O+		Mg+	•
						K₂O		sro	
155	0	19	6	37	0	38	0	o	TiO <sub>2</sub> +ZnO <sub>2</sub>
layer								1	+Al <sub>2</sub> O <sub>3</sub>
2 <sup>nd</sup>	0	22	21	30	5	21	1	o	ZrO <sub>2</sub> +
layer									Al <sub>2</sub> O <sub>3</sub>

In order to prepare the dielectric layer having a composition as shown in Table 8 in a shape of a green tape, PVB manufactured by Monsanto co., Ltd. was employed as a binder, mixture including toluene and isopropyl alcohol was employed as a solvent, dibutyl phthalate manufactured by Yakuri company was employed as a plasticizer, and KD-1 manufactured by ICI Chemical was employed as a dispersing agent.

Herein, a binder of 10 wt%, a solvent of 20 wt%, a plasticizer of 20 wt%, and a dispersing agent of 1 wt% were added in the powder mixture of 100 wt% for the barrier walls, in which glass powder and filler are mixed. The solvent of 20 wt% includes toluene of 8 wt% and isopropyl alcohol of 2 wt%, mixed therein. As a

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result, the barrier walls were formed in a shape of green tapes having a viscosity of 9500±500 cps. In this case, each of the barrier walls consists of two overlapping layers.

Table 9 shows properties of the barrier wall according to experiment 3.

Table 9
Properties of the barrier wall according to experiment
3:

cla		Soften-	Thermal	Average	Dielec-	Reflec	Etching
i		ing	expansive	particle	tric	-tion	rate
		tempera-	coeffic.	dia.	const.	ratio	(μm/Min
		ture	(x 10 <sup>-7</sup> /℃)	(μm)		(%)	,
		(℃)					
Parti	1 <sup>st</sup>	475	79	3.5	20	65	42.0
-tion	layer						
wall	2 <sup>nd</sup>	481	93	9.1	17	67	30.9
	layer						

Hereinafter, a method of integrating the dielectric layer and the barrier wall layer with each other will be briefly described.

After the dielectric layer was cast, the first and second layers of the barrier wall layer were sequentially cast on the upper surface of the dielectric layer, and then each layer was preliminary dried at 75°C, so that a lamination of dielectric layer/barrier wall layer having a shape of an

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integrated green tape was formed. Then, the lamination of dielectric layer/barrier wall layer was completely dried at 145℃, and was then attached to the upper surfaces of the electrodes and the glass substrate by a roller at a pressure of 0.3 MPa and temperature of 105℃. Thereafter, the lamination of dielectric layer/barrier wall layer was baked for fifteen minutes maximum temperature of 550°C, so that at dielectric layer was formed to have a thickness of 23  $\mu$ m and the barrier wall layer was formed to have a thickness of 130  $\mu$ m. In the barrier wall layer, the first layer was formed to have a thickness of 103  $\mu m$  and the second layer was formed to have a thickness of 27  $\mu$ m.

Thereafter, barrier walls were formed by working the partition layer in the same manner as in experiment 1, so that each barrier wall had an uppermost portion with a width of 60  $\mu$ m and a lowermost portion with a width of 130  $\mu$ m.

Further, phosphorous layers were formed in the same manner as in experiment 1. Each phosphorous layer was formed to have a thickness of 13 µm.

Table 10 shows properties of PDPs employing a rear plate according to experiment 3 and a conventional rear plate, respectively.

#### Table 10

Measured properties of PDPs employing a rear plate according to experiment 3 and a conventional rear

plate:

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prace	<u> </u>			
		Class	PDP	PDP
			employing	employing
			conventional	rear plate
			rear plate	of
				experiment 3
		Pitch	220 <i>μ</i> m	220 <i>µ</i> m
	Number	of firings of rear plate	4 times	3 times
		Discharge space	100%	105%
Opt	ical	White Peak brightness	100%	125%
prope	rties	Color temperature(K)	8500	8647
		Contrast	100%	120%
Elect	rical	Voltage margin	100%	125%
prope	rties	Power consumption	100%	92%
		Module efficiency	100%	115%
relia	bility	High temp./low temp. erroneous	No	No
	!	discharge		
		· vibration/drop test	ИО	No
			progressive	progressive
			defect	defect
Ot	her	noise (dB)	100%	75%
prope	rties			

As apparent from table 10, like the PDPs employing rear plates according to experiments 1 and 2, a PDP employing a rear plate according to experiment 3 of the present invention has shown improvement in electric and optical characteristics and reliability, in comparison with a PDP employing a conventional rear plate.

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Further, as noted from experiments 1, 2, and 3 of the present invention, in a PDP employing a rear plate according to the present invention, each barrier wall has a narrower lower portion than that in a PDP employing the conventional rear plate, so that the discharge space increases 5% and the number of firing times can be reduced.

## Industrial Applicability

As can be seen from the foregoing, in a rear plate of a plasma display panel according to the present invention, a dielectric layer or a barrier wall layer is formed by forming slurry in a tape of a green tape and then attaching the green tape to upper surfaces of electrodes and a glass substrate. Therefore, a PDP employing a rear plate according to the present invention has superior electric and optical characteristics.

While this invention has been described in connection with what is presently considered to be the most practical and preferred embodiment, it is to be understood that the invention is not limited to the disclosed embodiment and the drawings, but, on the contrary, it is intended to cover various modifications and variations within the spirit and scope of the appended claims.

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#### Claims

1. A rear plate of a plasma display panel, the rear plate comprising:

a glass substrate;

electrodes formed in a shape of patterns on an upper surface of the glass substrate;

a dielectric layer formed on upper surfaces of the electrode and the upper surface of the glass substrate;

barrier walls formed in a shape of a pattern through etching on an upper surface of the dielectric layer; and

phosphorous layers formed on side surfaces and bottom surfaces of the barrier walls, wherein:

each of the electrodes has a thickness of 2 to 8  $\mu m$  and a specific resistance of 1.0  $\times$  10<sup>-6</sup> to 5.0  $\times$  10<sup>-6</sup>  $\Omega cm_{i}$ 

the dielectric layer is made from a first mixture which includes a first filler and at least one glass powder selected from among a first glass powder and a second glass powder, the first glass powder including PbO of 30 to 80 wt%, ZnO of 0 to 20 wt%, SiO<sub>2</sub> of 0 to 20 wt%, B<sub>2</sub>O<sub>3</sub> of 5 to 40 wt%, Al<sub>2</sub>O<sub>3</sub> of 0 to 12 wt%, Na<sub>2</sub>O+K<sub>2</sub>O+Li<sub>2</sub>O of 0 to 5 wt%, and BaO+CaO+MgO+SrO of 0 to 5 wt%, the second glass powder including Bi<sub>2</sub>O<sub>3</sub> of 36 to 84 wt%, B<sub>2</sub>O<sub>3</sub> of 5 to 28 wt%, PbO of 0 to 46 wt%, ZnO of 0 to 30 wt%, Al<sub>2</sub>O<sub>3</sub> of 0 to 13 wt%, SiO<sub>2</sub> of 0 to 10 wt%, Na<sub>2</sub>O+K<sub>2</sub>O+Li<sub>2</sub>O of 0 to 5 wt%, and BaO+CaO+MgO+SrO of 0 to 3 wt%, each of the first and second glass powders

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having an average particle diameter of 1 to 10  $\mu$ m, a softening temperature of 390 to 550 °C, and a thermal expansive coefficient of 63  $\times$  10<sup>-7</sup> to 83  $\times$  10<sup>-7</sup>/°C, the first filler having an average particle diameter of 0.01 to 10  $\mu$ m, the dielectric layer having a dielectric constant of 8 to 20, a reflectance of 50 to 80%, an etching rate of 0.01 to 1.0  $\mu$ m/min with respect to inorganic acid, and a thickness of 10 to 30  $\mu$ m;

the barrier walls are made from a second mixture which includes a second filler, organic material, additives, and at least one glass powder selected from the group consisting of a third, fourth, and fifth glass powders, the third glass powder including ZnO of 0 to 48 wt%,  $SiO_2$  of 0 to 21 wt%,  $B_2O_3$  of 25 to 56 wt%,  $Al_2O_3$  of 0 to 12 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 38 wt%, and BaO+CaO+MgO+SrO of 0 to 15 wt%, the fourth glass powder including PbO of 25 to 65 wt%, ZnO of 0 to  $3\frac{1}{5}$  wt%, SiO<sub>2</sub> of 0 to 26 wt%,  $B_2O_3$  of 0 to 30 wt%,  $Al_2O_3+SriO_2$  of 0 to 13 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 19 wt%, BaO of 0 to 26 wt%, and CaO+MgO+SrO of 0 to 13 wt%, the fifth glass powder including PbO of 35 to 55 wt%,  $B_2O_3$  of 18 to 25 16 wt%, BaO of 0 to ZnO of 0 to 35 wt%,  $SiO_2+Al_2O_3+SnO_2$  of 0 to 9 wt%,  $CoO+CuO+MnO_2+Fe_2^{\dagger}O_3$  of 0 to 15 wt%, Na<sub>2</sub>O+K<sub>2</sub>O+Li<sub>2</sub>O of 0 to 19 wt%, and CaO+MgO+SrO of 0 to 13 wt%, the third glass powder having a softening temperature of 460 to 630 °C, a thermal expansive coefficient of 64  $\times$  10<sup>-7</sup> to 105  $\times$  10<sup>-7</sup>/°C, and an average particle diameter of 0.5 to 17  $\mu m$ , each of the fourth and fifth glass powders having a softening temperature

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of 390 to 550 °C, a thermal expansive coefficient of 63  $\times$  10 <sup>7</sup> to 110  $\times$  10 <sup>-7</sup>/°C, and an average particle diameter of 0.5 to 17  $\mu m$ , the second filler having an average particle diameter of 0.01 to 10  $\mu m$ , the barrier walls being formed with a height of 100 to 180  $\mu m$  by attaching a barrier wall layer formed in a shape of green tapes to an upper surface of the dielectric layer, firing the barrier wall layer together with the dielectric layer at a temperature between 400°C and 700°C, and then etching the barrier wall layer, the barrier wall layer having a dielectric constant of 5 to 18, a reflectance of 40 to 80%, an etching rate of 1.0 to 50.0  $\mu m/min$  with respect to inorganic acid;

each of the phosphorous layers has a thickness of have

a difference between the thermal expansive coefficients of the dielectric layer and the barrier wall layer has a percentage between 0 and 10 %, and a difference between the softening temperatures of the dielectric layer and the barrier wall layer has a value between 0 and 20 °C.

2. A rear plate of a plasma display panel, the rear plate comprising:

a glass substrate;

electrodes formed in a shape of patterns on an upper surface of the glass substrate;

a dielectric layer formed on upper surfaces of the electrode and the upper surface of the glass substrate;

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barrier walls formed in a shape of a pattern through etching on an upper surface of the dielectric layer; and

phosphorous layers formed on side surfaces and bottom surfaces of the barrier walls, wherein:

each of the electrodes has a thickness of 2 to 8  $\,$  µm and a specific resistance of 1.0  $\times$  10  $^{-6}$  to 5.0  $\times$  10  $^{-6}$   $\,$   $\Omega cm;$ 

the dielectric layer is made from a first mixture first filler, organic material, includes a additives, and at least one glass powder selected from among a first glass powder and a second glass powder, the first glass powder including PbO of 30 to 80 wt%, ZnO of 0 to 20 wt%,  $SiO_2$  of 0 to 20 wt%,  $B_2O_3$  of 5 to 40 wt%,  $Al_2O_3$  of 0 to 12 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 5 wt%, and BaO+CaO+MgO+SrO of 0 to 5 wt%, the second glass powder including Bi<sub>2</sub>O<sub>3</sub> of 36 to 84 wt%, B<sub>2</sub>O<sub>3</sub> of 5 to 28 wt%, PbO of 0 to 46 wt%, ZnO of 0 to 30 wt%, Al2O3 of 0 to 13 wt%, SiO2 of 0 to 10 wt%, Na2O+K2O+Li2O of 0 to 5 wt%, and BaO+CaO+MgO+SrO of 0 to 3 wt%, each of the first and second glass powders having an average a softening 1 to 10 μm, diameter of particle temperature of 390 to 550 °C, and a thermal expansive coefficient of 63  $\times$  10<sup>-7</sup> to 83  $\times$  10<sup>-7</sup>/°C, the first filler having an average particle diameter of 0.01 to the dielectric layer having a dielectric 10 μm, constant of 8 to 20, a reflectance of 50 to 80%, an etching rate of 0.01 to 1.0 µm/min with respect to inorganic acid, and a thickness of 10 to 30 µm, the

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dielectric layer being formed in a shape of a green tape and then attached to upper surfaces of electrodes;

the barrier walls are made from a second mixture organic material, includes a second filler, which additives, and at least one glass powder selected from the group consisting of a third, fourth, and fifth glass powders, the third glass powder including ZnO of 0 to |48 wt%, SiO<sub>2</sub> of 0 to 21 wt%, B<sub>2</sub>O<sub>3</sub> of 25 to 56 wt%,  $Al_2O_3$  of 0 to 12 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 38 wt%, and BaO+CaO+MgO+SrO of 0 to 15 wt%, the fourth glass powder including PbO of 25 to 65 wt%, ZnO of 0 to 35 wt%,  $SiO_2$ of 0 to 26 wt%,  $B_2O_3$  of 0 to 30 wt%,  $Al_2O_3 + SnO_2$  of 0 to 13 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 19 wt%, BaO of 0 to 26 wt%, and CaO+MgO+SrO of 0 to 13 wt%, the fifth glass 15 powder including PbO of 35 to 55 wt%,  $B_2O_3$  of 18 to 25 35 wt%, BaO of 0 to 16 wt%, ZnO of 0 to wt%,  $SiO_2 + Al_2O_3 + SnO_2$  of 0 to 9 wt%,  $CoO + CuO + MnO_2 + Fe_2O_3$  of 0 to 15 wt%, Na<sub>2</sub>O+K<sub>2</sub>O+Li<sub>2</sub>O of 0 to 19 wt%, and CaO+MgO+SrO of 0 to 13 wt%, the third glass powder having a softening 20 temperature of 460 to 630 °C, a thermal expansive coefficient of  $64 \times 10^{-7}$  to  $105 \times 10^{-7}/^{\circ}$ C, and an average particle diameter of 0.5 to 17  $\mu\text{m}$ , each of the fourth and fifth glass powders having a softening temperature of 390 to 550 °C, a thermal expansive coefficient of 63 25  $\times$  10<sup>-7</sup> to 110  $\times$  10<sup>-7</sup>/°C, and an average particle diameter of 0  $\mid$  5 to 17  $\mu\text{m}$ , the second filler having an average particle diameter of 0.01 to 10  $\mu\text{m}$ , the barrier walls being formed with a height of 100 to 180  $\mu m$  by

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attaching a barrier wall layer formed in a shape of green tapes to an upper surface of the dielectric layer, firing the barrier wall layer together with the dielectric layer at a temperature between 400°C and 700°C, and then etching the barrier wall layer, the barrier wall layer having a dielectric constant of 5 to 18, a reflectance of 40 to 80%, and an etching rate of 1.0 to  $50.0~\mu\text{m/min}$  with respect to inorganic acid;

each of the phosphorous layers has a thickness of

a difference between the thermal expansive coefficients of the dielectric layer and the barrier wall layer has a percentage between 0 and 10 %, and a difference between the softening temperatures of the dielectric layer and the barrier wall layer has a value between 0 and 20 °C.

3. A rear plate of a plasma display panel, the rear plate comprising:

a glass substrate;

electrodes formed in a shape of patterns on an upper surface of the glass substrate;

a dielectric layer formed on upper surfaces of the electrode and the upper surface of the glass substrate;

barrier walls formed in a shape of a pattern through etching on an upper surface of the dielectric layer; and

phosphorous layers formed on side surfaces and bottom surfaces of the barrier walls, wherein:

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each of the electrodes has a thickness of 2 to 8  $\mu m$  and a specific resistance of 1.0  $\times$  10  $^{-6}$  to 5.0  $\times$  10  $^{-6}$   $\Omega cm$  :

the dielectric layer is made from a first mixture organic material, filler, includes а first which additives, and at least one glass powder selected from among a first glass powder and a second glass powder, the first glass powder including PbO of 30 to 80 wt%, ZnO of 0 to 20 wt%,  $SiO_2$  of 0 to 20 wt%,  $B_2O_3$  of 5 to 40 wt%,  $Al_2O_3$  of 0 to 12 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 5 wt%, and \$aO+CaO+MgO+SrO of 0 to 5 wt%, the second glass powder including  $Bi_2O_3$  of 36 to 84 wt%,  $B_2O_3$  of 5 to 28 wt%, PbO of 0 to 46 wt%, ZnO of 0 to 30 wt%, Al2O3 of 0 to 13 wt%,  $SiO_2$  of 0 to 10 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 5 wt%, and BaO+CaO+MgO+SrO of 0 to 3 wt%, each of the first and second glass powders having an а softening 10 μm, particle diameter of 1 to temperature of 390 to 550 °C, and a thermal expansive coefficient of  $63 \times 10^{-7}$  to  $83 \times 10^{-7}$ /°C, the first filler having an average particle diameter of 0.01 to dielectric dielectric layer having a the constant of 8 to 20, a reflectance of 50 to 80%, an etching rate of 0.01 to 1.0  $\mu m/min$  with respect to inorganic acid, and a thickness of 10 to 30  $\mu m$ , the dielectric layer being formed in a shape of a green tape;

the barrier walls are made from a second mixture which includes a second filler, organic material, additives, and at least one glass powder selected from

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the group consisting of a third, fourth, and fifth glass powders, the third glass powder including ZnO of 0 to 48 wt%,  $SiO_2$  of 0 to 21 wt%,  $B_2O_3$  of 25 to 56 wt%,  $Al_2O_3$  of 0 to 12 wt%,  $Na_2O+K_2O+Li_2O$  of 0 to 38 wt%, and BaO+CaO+MgO+SrO of 0 to 15 wt%, the fourth glass powder including PbO of 25 to 65 wt%, ZnO of 0 to 35 wt%, SiO2 of 0 to 26 wt%, B2O3 of 0 to 30 wt%, Al2O3+SnO2 of 0 to 13 wt%, Na<sub>2</sub>O+K<sub>2</sub>O+Li<sub>2</sub>O of 0 to 19 wt%, BaO of 0 to 26 wt%, and CaO+MgO+SrO of 0 to 13 wt%, the fifth glass powder including PbO of 35 to 55 wt%, B2O3 of 18 to 25 ZnO of 0 to 35 wt%, BaO of 0 to  $SiO_2+Al_2O_3+SnO_2$  of 0 to 9 wt%,  $CoO+CuO+MnO_2+Fe_2O_3$  of 0 to 15 wt%, Na<sub>2</sub>O+K<sub>2</sub>O+Li<sub>2</sub>O of 0 to 19 wt%, and CaO+MgO+SrO of 0 to 13 wt%, the third glass powder having a softening temperature of 460 to 630 °C, a thermal expansive coefficient of  $64 \times 10^{-7}$  to  $105 \times 10^{-7}$ /°C, and an average particle diameter of 0.5 to 17 µm, each of the fourth and fifth glass powders having a softening temperature of 390 to 550 °C, a thermal expansive coefficient of 63  $\times$  10<sup>-7</sup> to 110  $\times$  10<sup>-7</sup>/°C, and an average particle diameter of 0.5 to 17  $\mu\text{m}$ , the second filler having an average particle diameter of 0.01 to 10 µm;

each of the phosphorous layers has a thickness of 10 to 50 μm; and

a difference between the thermal expansive coefficients of the dielectric layer and the barrier wall layer has a percentage between 0 and 10 %, and a difference between the softening temperatures of the dielectric layer and the barrier wall layer has a value

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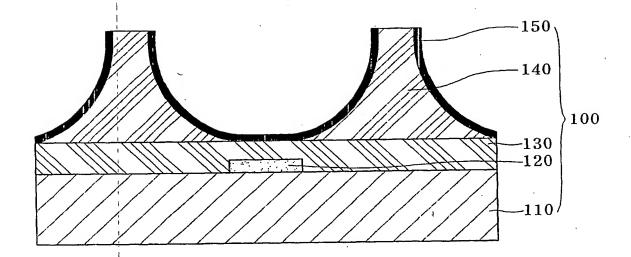
between 0 and 20 °C, wherein

a barrier wall layer formed in a shape of green tapes, which has a dielectric constant of 5 to 18, a reflectance of 40 to 80%, and an etching rate of 1.0 to μm/min with respect to inorganic acid, 50.0 layer to form a integrated with the dielectric lamination of dielectric layer/ barrier wall layer, and the lamination of dielectric layer/ barrier wall layer is attached to the upper surfaces of the electrodes and the glass substrate, is baked at a temperature between 400°C and 700 °C, and is then etched, so that the barrier walls are formed with a height of 100 to 180 μm.

4. A rear plate of a plasma display panel as claimed in any of claims 1 to 3, wherein each of the barrier walls has at least two different layers having different etching rates with respect to inorganic acid.

1/3

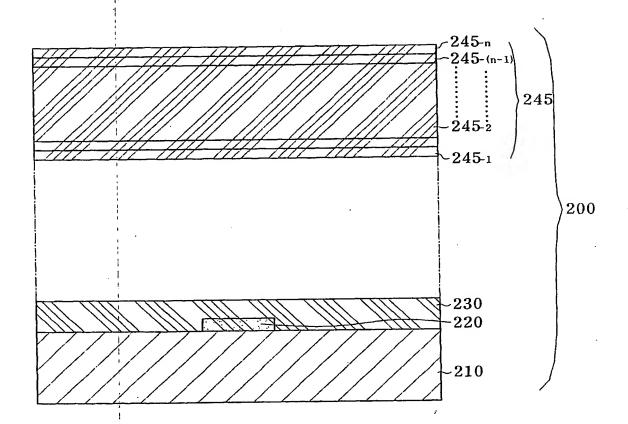
FIG. 1



2/3

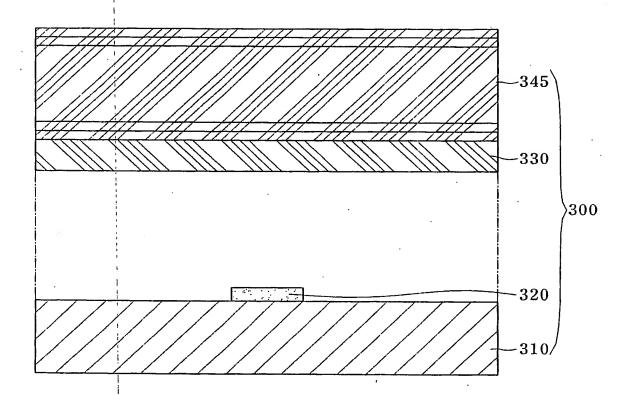
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FIG. 2



3/3

FIG. 3





### INTERNATIONAL SEARCH REPORT

International application No.
PCT/KR02/02316

A. CLAS	A. CLASSIFICATION OF SUBJECT MATTER							
IPC7	IPC7 H0IJ 17/49							
According to L	According to International Patent Classification (IPC) or to both national classification and IPC							
B. FIEL	DS SEARCHED							
Minimum doc	mentation searched (classification system followed by	classification symbols)						
IPC HOIJ	G09G C09D							
D	n searched other than minimum documentation to the	the the such decuments are included in the f	ieldo searched					
Documentation	a seasoned other than immindia documentation to the c	Atelit that such documents are mended at the s	ional commissi					
Electronic data	base consulted during the international search (name	of data base and, where practicable, search terr	ns used)					
Diccuoine date	Description during the first distribute someth (maile	or data base and, where productive or, or a minimum	,					
C. DOCUM	MENTS CONSIDERED TO BE RELEVANT							
Category*	Citation of document, with indication, where app	ropriate, of the relevant passages	Relevant to claim No.					
Α ]	WO 99/24999 A1(AOKI MASAKI, KADO HIROY	UKI) 20 May 2000	1					
	see claims 11,12							
Т	JP 15-2692 A(FUJMINE SATORU) 08 Jan	2003	1,2,3					
	see entire document, claims 1,3,5							
A	JP 12-169764 A(YAMASHITA TAKANORI) 20 J	une 2000	1					
	see entire document							
T	JP 15-2693 A(FUJMINE SATORU) 08 Jan	2003	1,2,3					
	see entire document, claims 7							
	<u>.</u>							
i								
			į					
Further	documents are listed in the continuation of Box C.	X See patent family annex.						
	ategories of cited documents: defining the general state of the art which is not considered	"T" later document published after the internation date and not in conflict with the application						
to be of pe	articular relevance	the principle or theory underlying the inver-	tion					
"E" earlier ap	plication or patent but published on or after the international	"X* document of particular relevance; the claims considered novel or cannot be considered						
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"O" document means	O" document referring to an oral disclosure, use, exhibition or other combined with one or more other such documents, such combination							
"P" document	"P" document published prior to the international filing date but later "&" document member of the same patent family							
	than the priority date claimed							
1	nual completion of the international search	Date of mailing of the international search re						
20	26 AUGUST 2003 (26.08.2003) 27 AUGUST 2003 (27.08.2003)							
	iling address of the ISA/KR	Authorized officer	APEIIIRA					
-300	Korean Intellectual Property Office 920 Dunsan-dong, Seo-gu, Daejeon 302-701, KANG, Byung Sub							
40	Republic of Korea	Telephone No. 82-42-481-5965	MOUDIEN					
Lacamine Mo.	82-42-472-7140							

## INTERNATIONAL SEARCH REPORT

Information on patent family members

International application No.
PCT/KR02/02316

Patent document cited in search report	Publication date	Patent family member(s)	Publication date
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JP 15-2692 A	08-01-03	None	
JP 12-169764 A	20-06-00	None	
JP 15-2693 A	08-01-03	None	

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